

# Device Modeling Report

COMPONENTS: Power MOSFET (Model parameter)  
PART NUMBER: 2SK3799  
MANUFACTURER: TOSHIBA  
Body Diode (Model parameter) / ESD Protection Diode



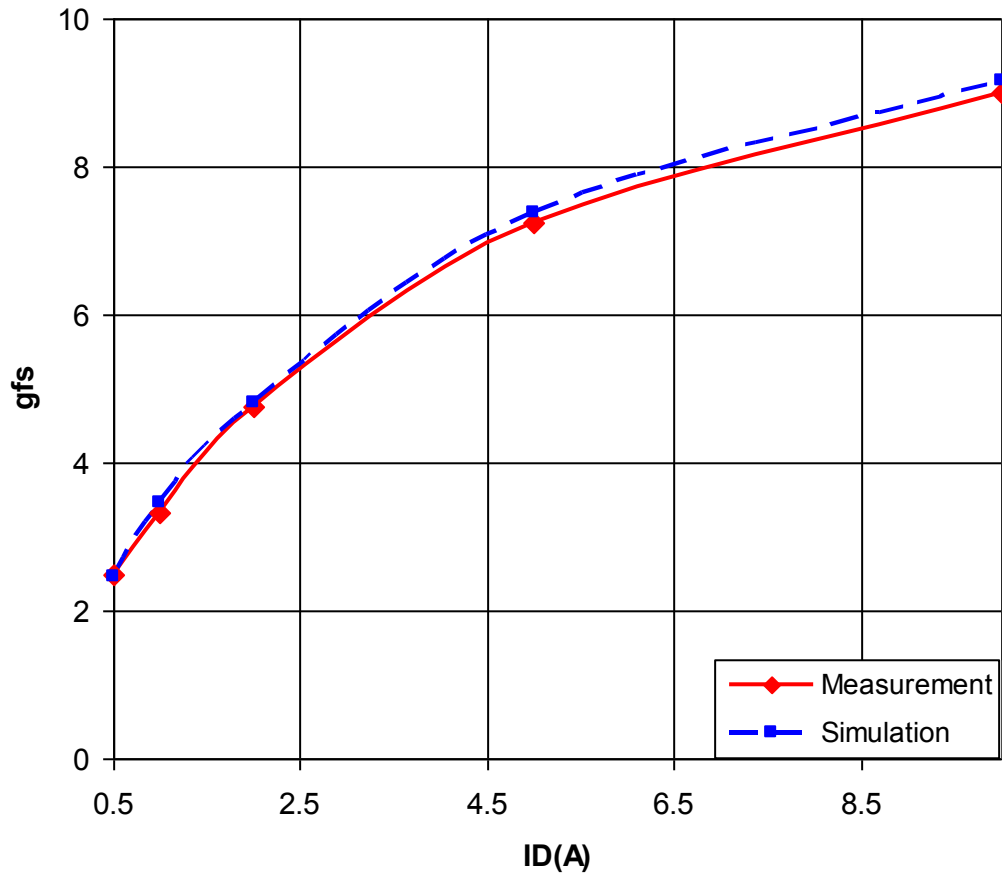
**Bee Technologies Inc.**

## MOSFET MODEL

PSpice model parameter	Model description
LEVEL	
L	Channel Length
W	Channel Width
KP	Transconductance
RS	Source Ohmic Resistance
RD	Ohmic Drain Resistance
VTO	Zero-bias Threshold Voltage
RDS	Drain-Source Shunt Resistance
TOX	Gate Oxide Thickness
CGSO	Zero-bias Gate-Source Capacitance
CGDO	Zero-bias Gate-Drain Capacitance
CBD	Zero-bias Bulk-Drain Junction Capacitance
MJ	Bulk Junction Grading Coefficient
PB	Bulk Junction Potential
FC	Bulk Junction Forward-bias Capacitance Coefficient
RG	Gate Ohmic Resistance
IS	Bulk Junction Saturation Current
N	Bulk Junction Emission Coefficient
RB	Bulk Series Resistance
PHI	Surface Inversion Potential
GAMMA	Body-effect Parameter
DELTA	Width effect on Threshold Voltage
ETA	Static Feedback on Threshold Voltage
THETA	Mobility Modulation
KAPPA	Saturation Field Factor
VMAX	Maximum Drift Velocity of Carriers
XJ	Metallurgical Junction Depth
UO	Surface Mobility

# Transconductance Characteristic

## Circuit Simulation Result

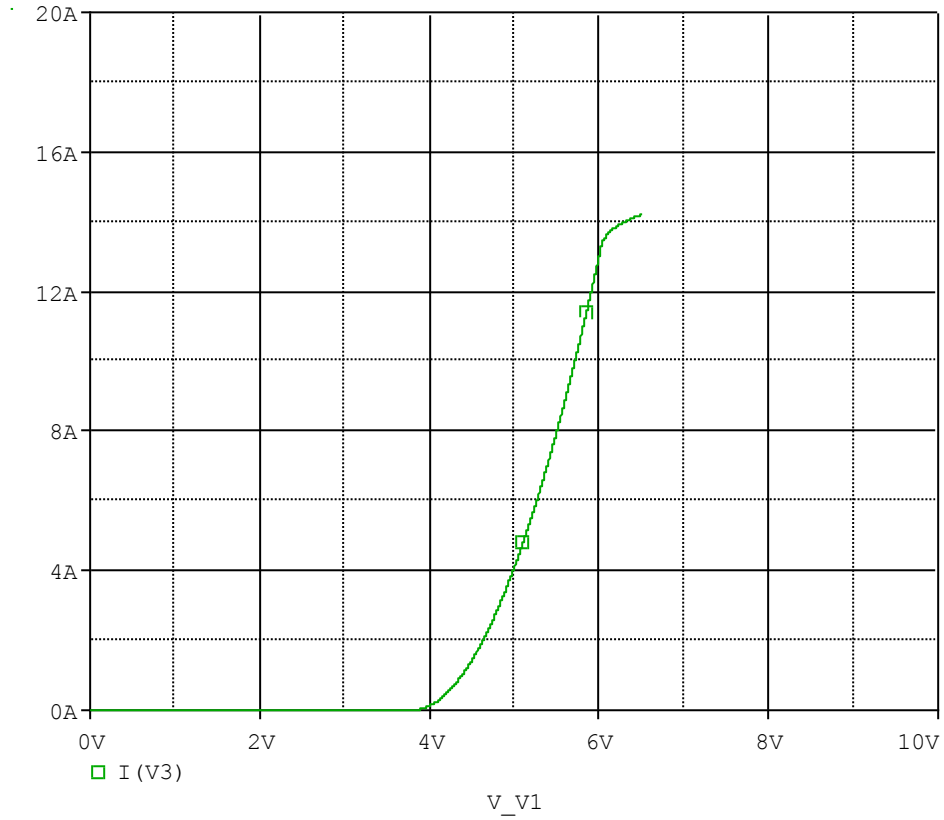


## Comparison table

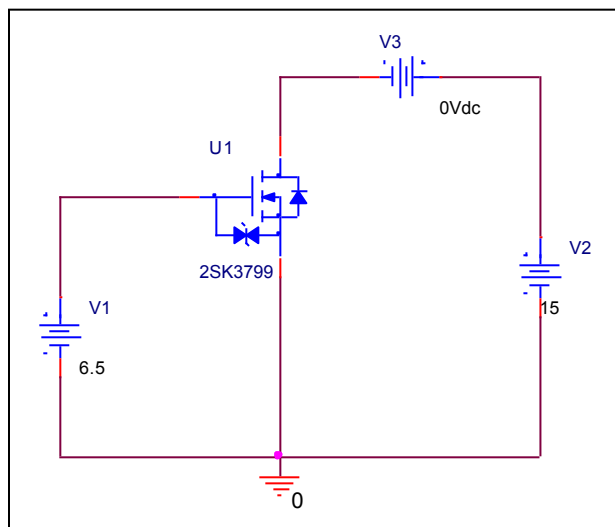
Id(A)	gfs		Error (%)
	Measurement	Simulation	
0.5	2.5	2.463	-1.480
1	3.333	3.448	3.450
2	4.762	4.808	0.966
5	7.246	7.386	1.932
10	8.989	9.164	1.947

# Vgs-I<sub>d</sub> Characteristic

## Circuit Simulation result

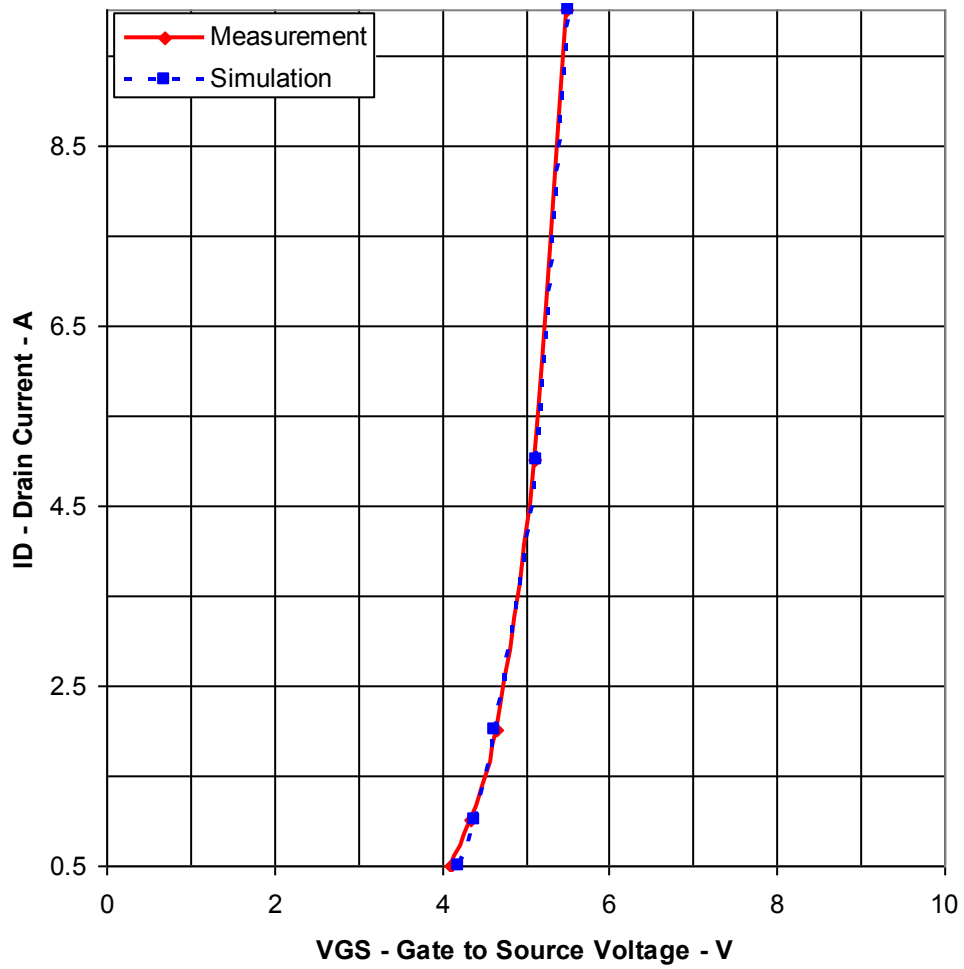


## Evaluation circuit



## Comparison Graph

### Circuit Simulation Result

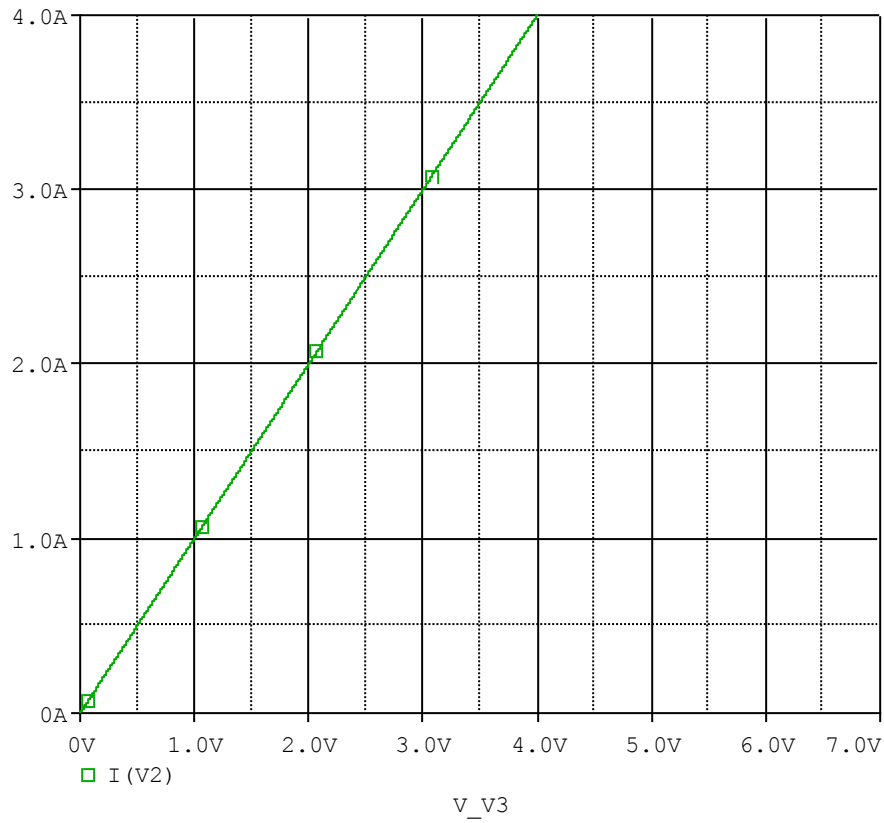


### Simulation Result

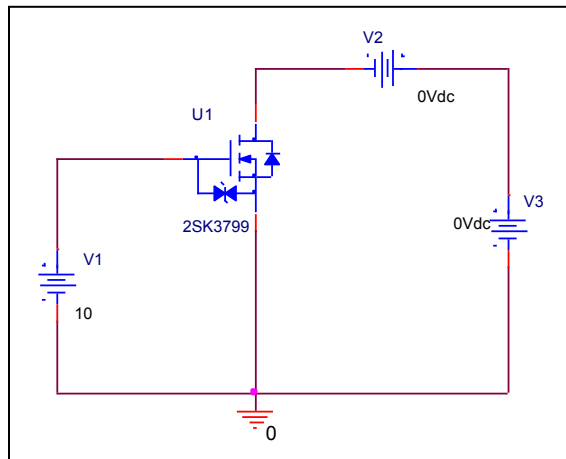
$I_D$ (A)	$V_{GS}$ (V)		Error (%)
	Measurement	Simulation	
0.5	4.1	4.2106	2.698
1	4.35	4.3839	0.779
2	4.65	4.6318	-0.391
5	5.1	5.134	0.667
10	5.5	5.5044	0.080

## R<sub>ds(on)</sub> Characteristic

### Circuit Simulation result



### Evaluation circuit

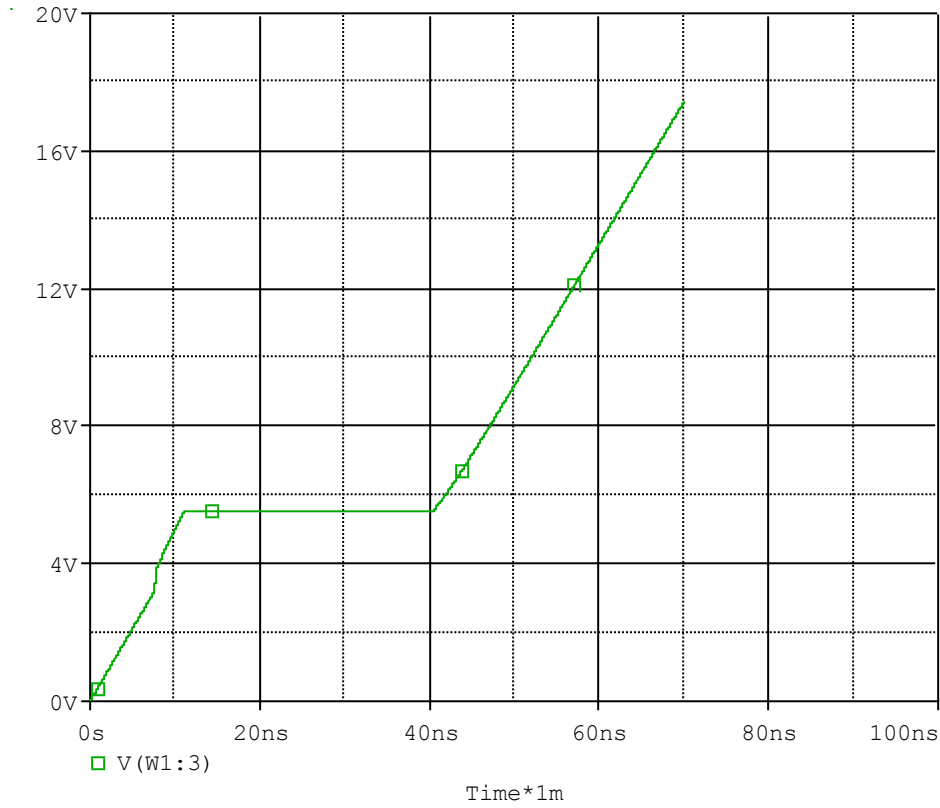


### Simulation Result

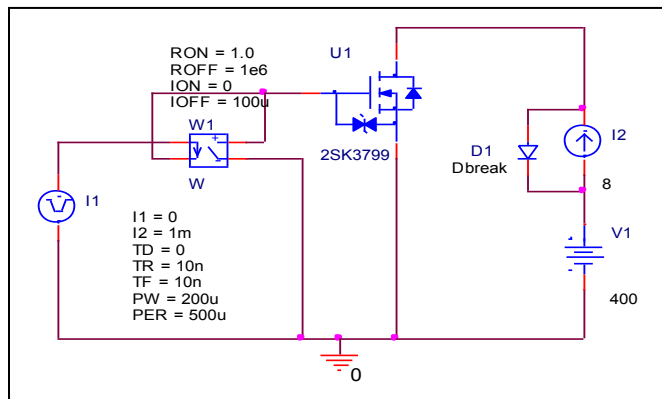
<b>I<sub>D</sub>=4A, V<sub>GS</sub>=10V</b>	<b>Measurement</b>		<b>Simulation</b>		<b>Error (%)</b>
<b>R<sub>DS (on)</sub></b>	<b>1</b>	<b>Ω</b>	<b>1</b>	<b>Ω</b>	<b>0</b>

# Gate Charge Characteristic

## Circuit Simulation result



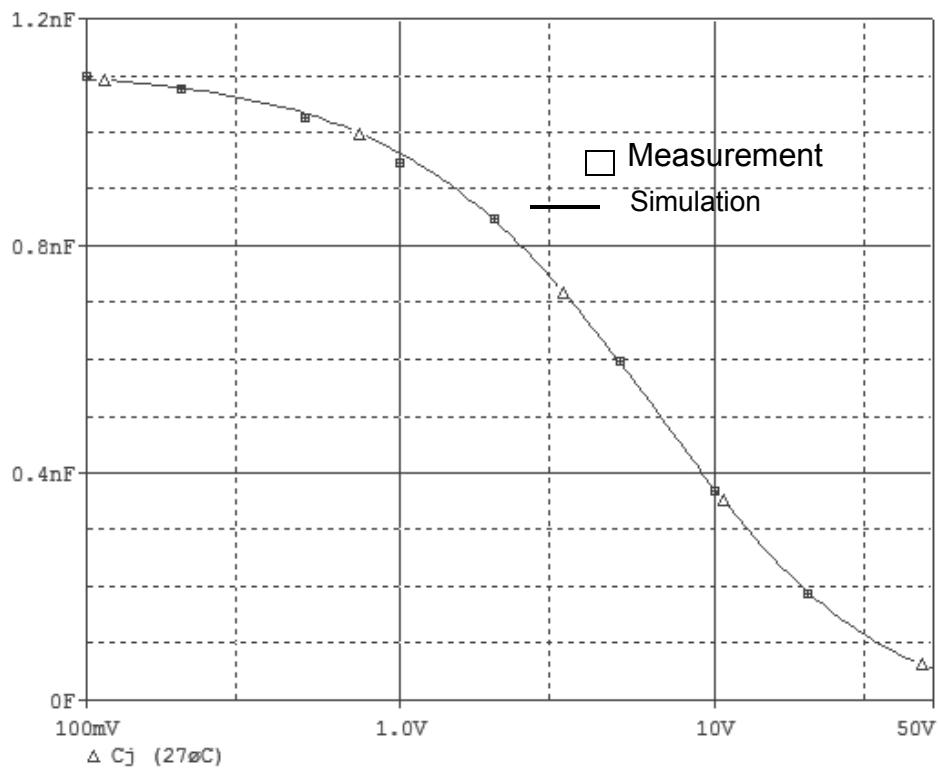
## Evaluation circuit



## Simulation Result

$V_{DD}=400V, I_D=8A$	Measurement		Simulation		Error (%)
<b>Qgs</b>	<b>11</b>	<b>nC</b>	<b>11.107</b>	<b>nC</b>	<b>0.973</b>
<b>Qgd</b>	<b>29</b>	<b>nC</b>	<b>29.195</b>	<b>nC</b>	<b>0.672</b>
<b>Qg</b>	<b>62</b>	<b>nC</b>	<b>52.036</b>	<b>nC</b>	<b>-16.071</b>

## Capacitance Characteristic

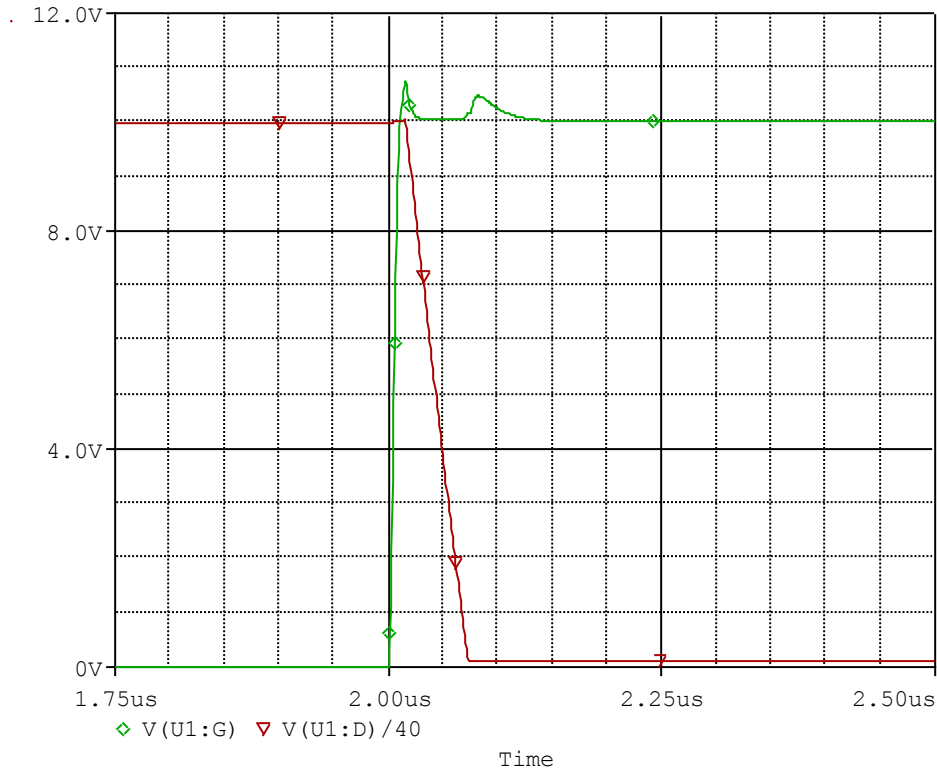


### Simulation Result

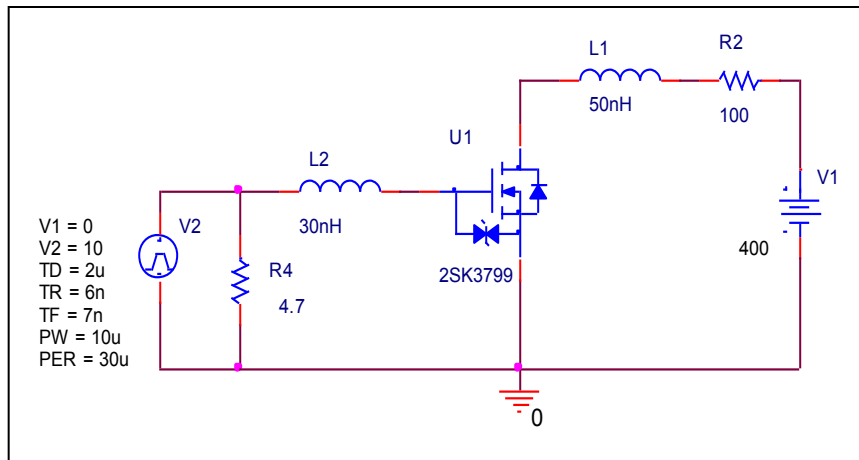
V <sub>DS</sub> (V)	Cbd(pF)		Error(%)
	Measurement	Simulation	
0.1	1100	1095	-0.455
0.2	1080	1078	-0.185
0.5	1030	1032	0.194
1	950	963	1.368
2	850	845	-0.588
5	600	595	-0.833
10	370	375	1.351
20	190	190	0

# Switching Time Characteristic

## Circuit Simulation result



## Evaluation circuit

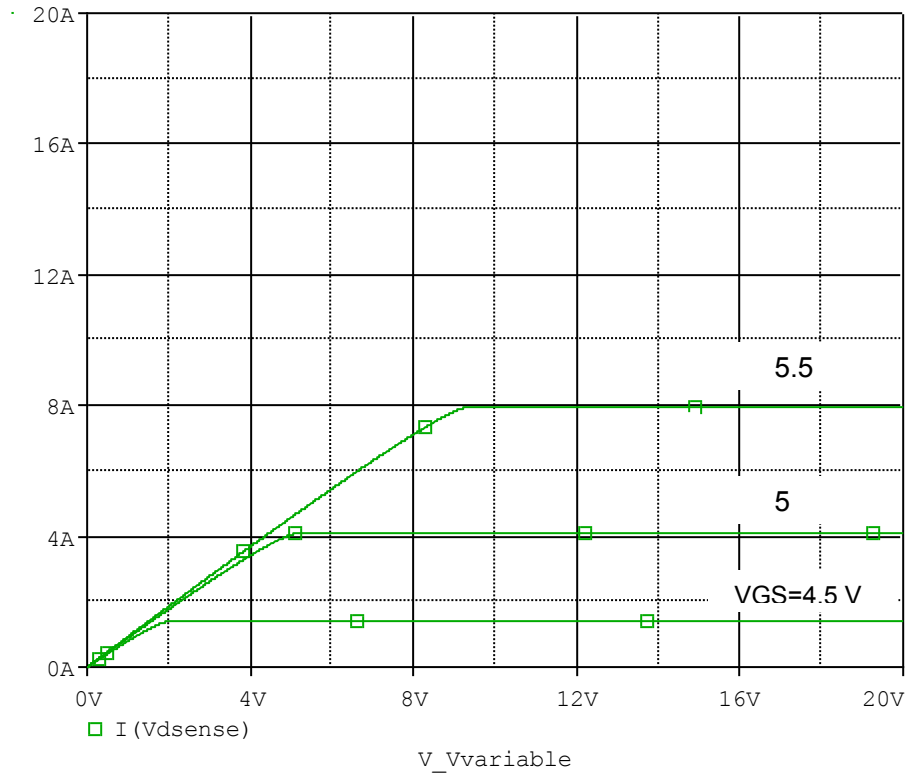


## Simulation Result

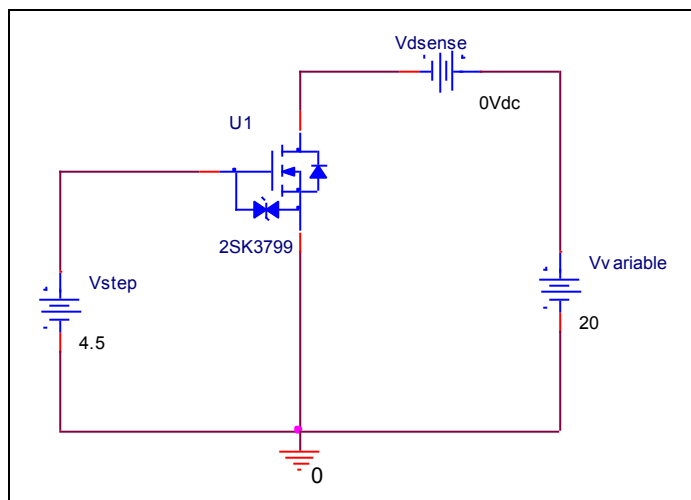
$I_D=4\text{ A}$ , $V_{DD}=400\text{ V}$ $V_{GS}=0/10\text{ V}$	Measurement		Simulation		Error(%)
	ton	ns	ns	ns	
	65.000	ns	65.045	ns	0.069

# Output Characteristic

## Circuit Simulation result

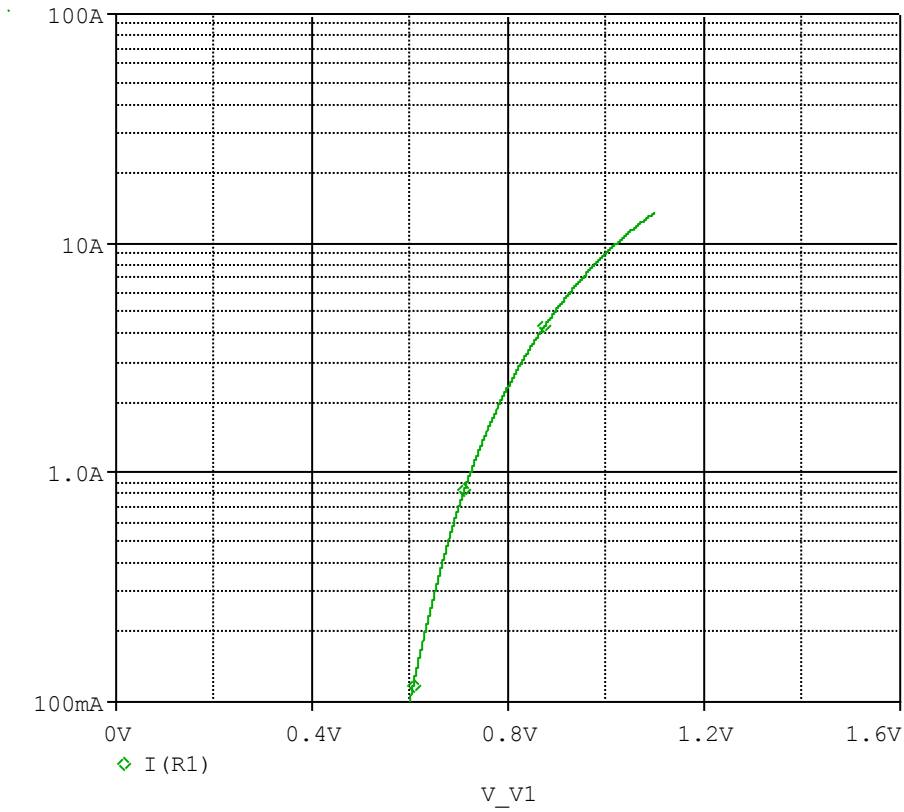


## Evaluation circuit

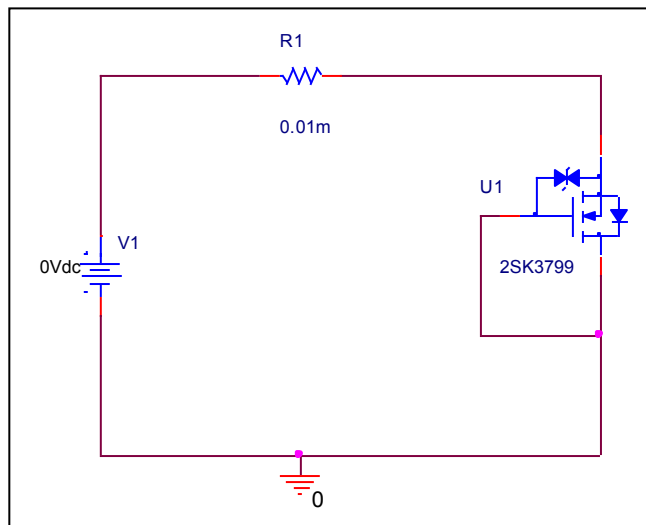


# BODY DIODE Forward Current Characteristic

## Circuit Simulation Result

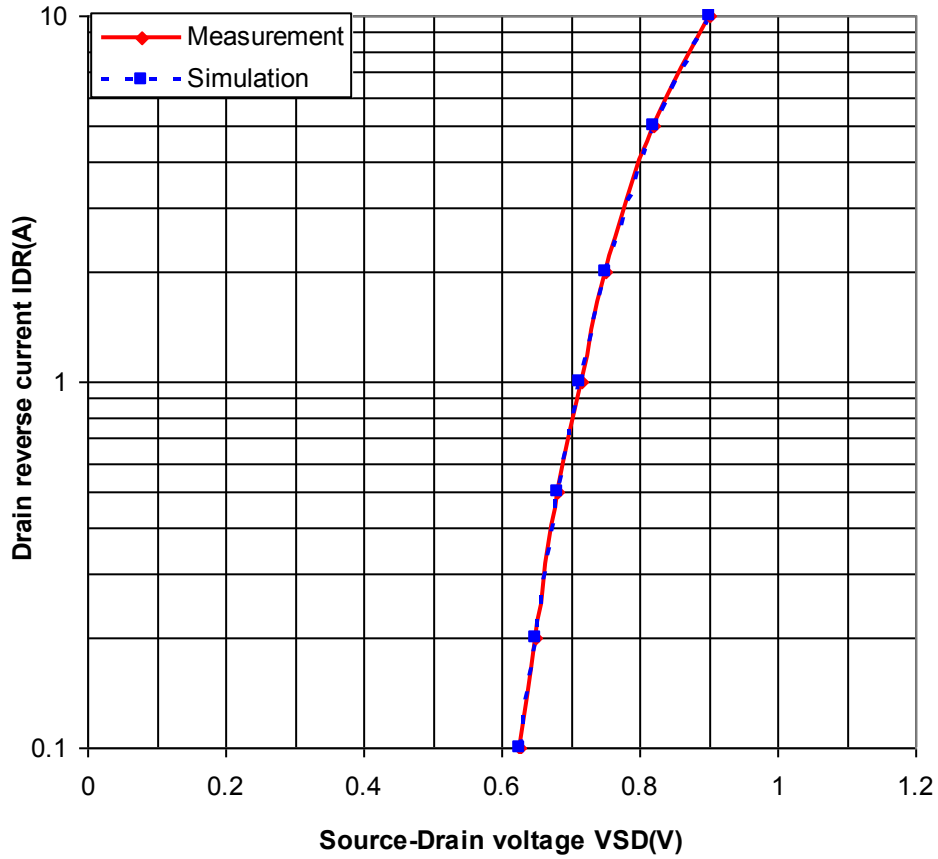


## Evaluation Circuit



## Comparison Graph

### Circuit Simulation Result

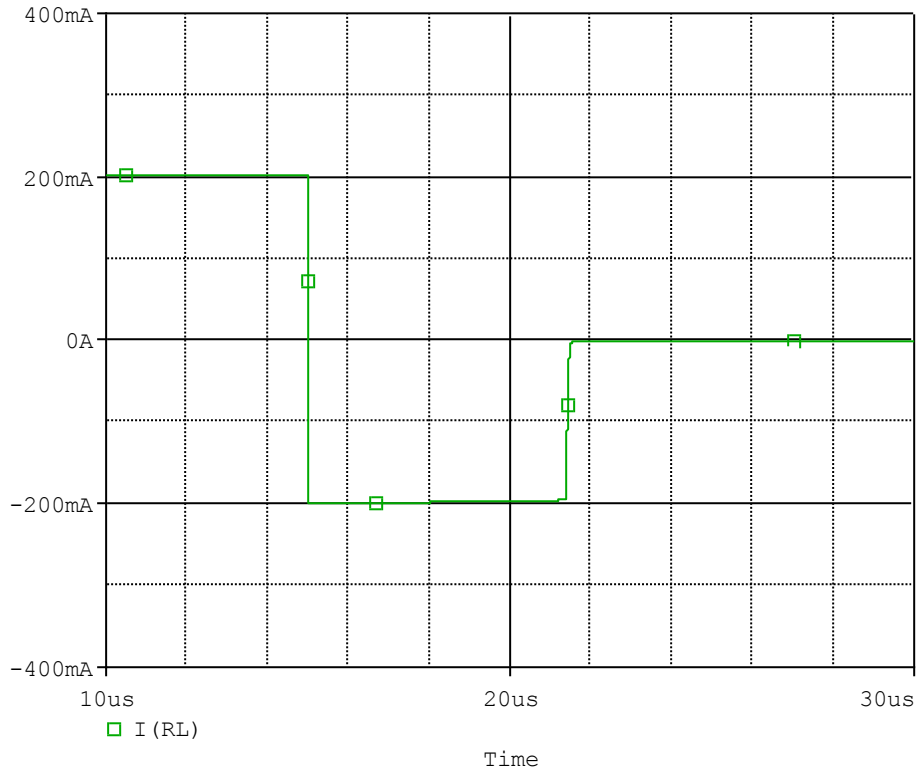


### Simulation Result

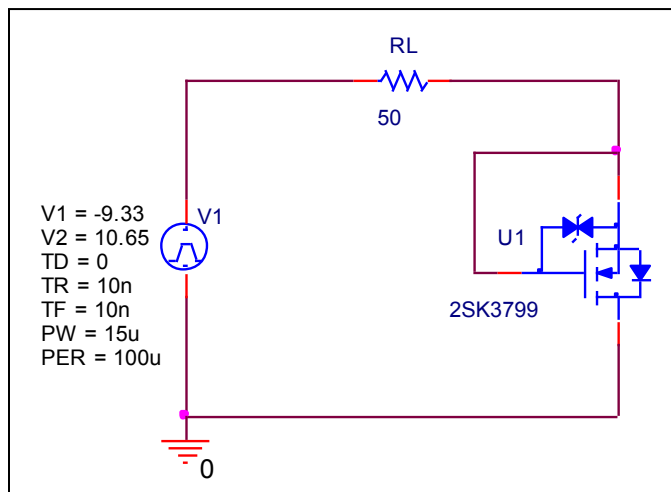
Ifwd(A)	VSD(V)		%Error
	Measurement	Simulation	
0.1	0.6	0.599	-0.167
0.2	0.63	0.63	0
0.5	0.68	0.678	-0.294
1	0.72	0.723	0.417
2	0.78	0.783	0.385
5	0.9	0.895	-0.556
10	1.02	1.022	0.196

# Reverse Recovery Characteristic

## Circuit Simulation Result



## Evaluation Circuit



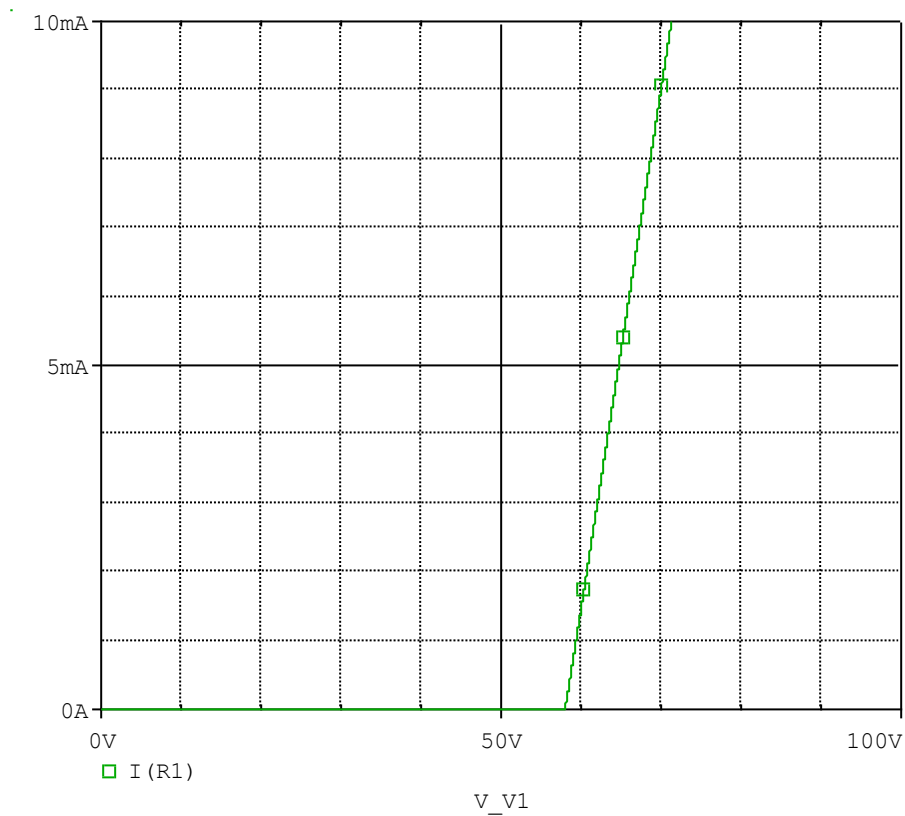
## Compare Measurement vs. Simulation

Trr(ns)	Measurement	Simulation	Error (%)
Trj+Trb (us)	6.44	6.4475	0.116

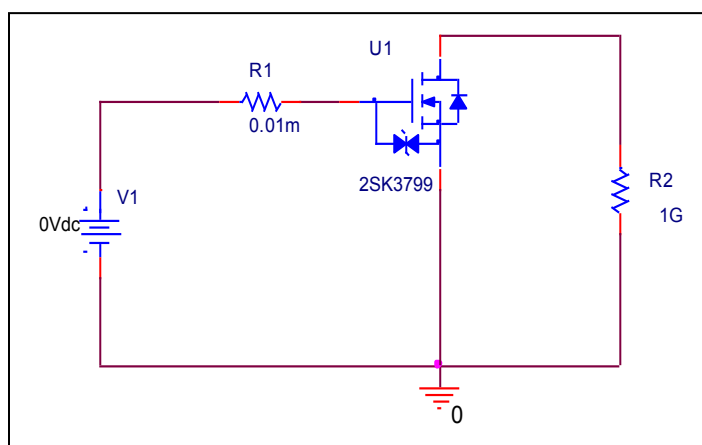


# ESD PROTECTION DIODE Zener Voltage Characteristic

## Circuit Simulation Result



## Evaluation Circuit



# Zener Voltage Characteristic

# Reference

